Preparation of Manganese Sulfide Thin Film by Thermal Evaporation Technique Deposition: Application of the Experimental Design Photodiode

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Abstract: Manganese Sulfide (MnS) thin films were prepared by thermal evaporation technique which deposited on a glass and silicon substrate. The deposited films were examined for their morphology and crystal structure by X-Ray Diffraction (XRD). The MnS heterojunction was successfully fabricated by using thermal evaporation technique at different temperature. The I-V properties of the heterogeneous MnS depend heavily on the structure. Silicon improves performance MnS shows good transparency in the spectral range 300-900 nm and the electrical properties of the system are highly dependent on the structure. The maximum value of the $R(\lambda)$ spectral response of the MnS detection amplifier is 0.165 A/W at $450 \pm 50 \text{ nm}$. The maximum detection value of $D(\lambda)$ was found around $2.359 \times 10^{12} \text{ (cm Hz}^{-1}\text{/W)}$ at $450 \pm 60 \text{ nm}$ wavelength of the MnS optical amplifier.

Key words: MnS, structural properties, optical properties, AFM, XRD, photodiode

INTRODUCTION

Manganese sulfide is a broad energy gap (3.1 eV) dilute magnetic semiconductor material that is of potential regard in short wavelength optoelectronic applications such as in photodetector selective coatings, solar cells, sensors, optical mass memories (Eckertova, 1977; Lokhande, 1991). Therefore, the knowledge of the optical properties of thin films is of significance for many applications. Manganese Sulfide (MnS) thin films or powders can be found in several polymorphic forms: the rock-salt type structure (α -MnS) which is the most common form by low temperature growing techniques it crystallizes into the zinc-blende (β -MnS) or wurtzite (γ -MnS) structure (Greene *et al.*, 1968; Fan *et al.*, 2003). Interesting electronic properties of manganese attracts a major attention in techno-logical applications. Manganese and its compounds have important semiconducting properties. Recently metal chalcogenide thin film materials have opened a new area in the field of electronic applications. Their properties can be changed by changing the crystallite size and/or thickness of the film depending upon the deposition conditions, the structural, electrical and optical properties of these materials can be controlled in many ways (Greene *et al.*, 1968; O'Brien *et al.*, 2000). Materials containing manganese are interesting because their applications are possible in many areas of modern technology. Manganese Sulfide (MnS) is a magnetic semiconductor material ($E_g = 3.1 \text{ eV}$) that is of potential interest in short wavelength

optoelectronic applications such as in solar selective coatings, solar cells, sensors, photoconductors, optical mass memories (Fan *et al.*, 2003; Tappero *et al.*, 1997; Lokhande *et al.*, 1998). MnS thin films or powders can be found in several polymorphic forms: the rock salt type structure (α -MnS) which is the most common form by low temperature growing techniques it crystallizes into the zinc blende (β -MnS) or wurtzite (γ -MnS) structure (Clendenen and Drickamer, 2006; Kobayashi *et al.*, 1995). MnS is extensively studied in the literature, preparation of its thin films has been carried out by different methods such as radiofrequency sputtering (Mayen-Hernandez *et al.*, 2003; Oidor-Juarez *et al.*, 2002), hydrothermal (Zhang *et al.*, 2002, 2003; An *et al.*, 2003), molecular beam epitaxy (David *et al.*, 2002) and Chemical Bath Deposition (CBD) (Lokhande *et al.*, 1998; Reddy, 2007). The properties of thin films prepared by different methods are critically dependent on the nature of preparation technique.

In this study, MnS has been fabricated by high vacuum thermal evaporation. Structural, morphology and optical of MnS has been investigated. The XRD measurements disclosed that the MnS was cubic crystal structure. AFM image showed that the produced MnS films have semi spherical shaped with a high homogenous. The energy band gap of MnS films which prepared by thermal evaporation technique has been deter-mined from optical measurements found to be around 3.05 eV. Dark and illuminated current-Voltage I-V characteristics, spectral responsivity, specific

detectivity and minority carrier lifetime of photodiode relieve that the MnS can be used as a photodiode application.

MATERIALS AND METHODS

Experimental work: The glass and silicon chip were used as substrate materials for deposition of thin MnS films. The glass slides were cut into 1.5×1.5 cm compatible with the dimension of the substrate holder using a steel cutting tool. The glass slides were thoroughly cleaned prior to the deposition process to reach the reasonable adhesion coefficient as followed in the following procedure. The glass slides were first cleaned using a diluted solution of chemical detergents to remove impurities and protein substances on the surface of the slides. Si samples were then cleaned with alcohol and an ultrasonic bath to remove impurities and debris from its surface. These substrates were drilled with HF (10%) for 5 min to remove the original oxide. The bottom electrode is coated with a thick aluminum layer prior to the anode process and electrical properties are measured. They are obtained under vacuum aluminum wire with high purity (99.99%). Evaporation process started at 10⁻⁵ torr pressure. The best state of good communication was met with a layer of 200 nm. The Manages Sulfide (MnS) deposited by thermal evaporation technique using coating unit in vacuum about 2×10⁻⁵ torr and put it in a special evaporation molybdenum boat. The rate of evaporation was 23.5 nm/min and the film = thickness (400 nm) was measured by interference method. The substrate glass was placed directly above the source at a distance about 18 cm after cleaned the glass and the this film which deposited one study the structural, topography

and optical properties of all films (as-prepared and 150°C) were investigated separately by means of (CuK α) XRD-6000, Shimadzu X-ray diffractometer, Fourier transformation infrared spectroscopy, JEOL (JSM-5600) scanning electron microscopy, Philips CM10 pw 6020 transmission electron microscopy, Angstrom AA3000 Atomic Force Microscopy and Cary 100 Conc plus UV-V is spectrophotometer. Infrared spectroscopy (FTIR-8400S) and Cary 100 Conc plus UV-Vis spectrophotometer.

RESULTS AND DISCUSSION

Figure 1 show the XRD different pattern of prepped thin films by thermal evaporation technique and deposited on glass substrate than annealing at tow temperature (as-prepared and 150°C). Figure 1 revels a strong peak of MnS (as prepared and 150°C) at 2 θ (29.66°, 29.692°), respectively only along the (111) direction at annealing temperature, correspond ASTM. All the diffraction peaks in Fig. 1 are indicates to cubic structure with no trail of hexagonal or other faces. The crystalline size C for a knowing by X-ray wavelength λ at the diffraction angle θ from Eq. 1 as given by Eckertova (1977):

$$C = \alpha \lambda / \text{FWHM} \cos(\theta) \quad (1)$$

Where:

FWHM : The Full Width at the Half Maximum of the characteristic spectrum in units of radians and λ (nm)

α : The Scherrer constant (1> α >0.89), fund to be (10.3 nm) which is agreement with the determined AFM in visitation

Fig. 1: (a) XRD spectra of MnS films and (b) MnS EDX

Fig. 2: 3D AFM images of MnS and granularity accumulation distribution chart

Fig. 3: FTIR spectra of MnS thin films

Fig. 4: Optical transmittance of MnS thin films

Table 1: Average grain, roughness density and RMS of thin films	
Samples	MnS (nm)
Average GS	70.01
Roughness	2.01
RMS	2.37

Figure 2 shows 3D AFM image and granularity accumulation distribution chart of MnS nanostructure prepared by thermal evaporation technique on glass substrate. Substrate is well covered with MnS nanostructure; distributed uniformly on the surface. It is obvious from Fig. 2 that the nanostructure has small ordered particles with semispherical shape. The average particle size estimated with the aid of software (Table 1).

Figure 3 shows the FTIR spectra of MnS: Al Sample which showed several significant absorption peaks. The

broad absorption band in the region of 600-2100 cm^{-1} is assigned to MnS stretching mode. The spectra of MnS showed the absorption bands at 620, 892 and 1123 cm^{-1} in control and treated sample, attributing to -OH stretching vibration.

Figure 4 shows displays the transmission as a function of wavelength of MnS thin films is which prepared by thermal evaporation techniques and deposited on glass substrate. It is obvious that the film gives good transparency characteristics at the spectral range 600-1000 nm. The data is corrected for glass in UV-region, the transmission is sharply increases because of the wide of absorbed particle size. Also, the maximum value of transmittance (90.1%) that is indicated as window on solar cell application at rang to N-IR or the material (MnS) can be describe in absorber material below 550 nm. The optical energy gap of MnS was calculated by the relation (Lokhande *et al.*, 1998):

$$\alpha h\nu = A(h\nu - E_g)^n \quad (2)$$

Where:

Aa = The constant

ν = The transition frequency and the exponent n characterizes the nature of band transition

The $n = 1/2$ and $n = 3/2$ corresponds to direct allowed and direct forbidden transitions and $n = 2$ and 3 corresponds to indirect allowed and indirect forbidden

Fig. 5: Plot of $(\alpha h\nu)^2$ versus $h\nu$ curve of as-prepared MnS thin films

Fig. 6: PL spectra of MnS

Fig. 7: Characteristic under forward reverse bias of the MnS for MnS

transitions, respectively. Figure 5 shows the band gap of MnS thin films is which prepared by thermal evaporation techniques and deposited on glass substrate. Measured from the plot of the square of $(\alpha h\nu)^2$ versus photon energy $h\nu$ (where α is the absorption coefficient) by extrapolating the linear part of the curve toward the photon energy axis. The optical energy gap of MnS thin film is found to be around 2.85 eV, this values are agree with the values obtained by Reddy *et al.* (2007).

Figure 6 shows the PL emission spectra of MnS prepared by thermal evaporation technique room temperature with an excitation source of wavelength of 400 nm, single sharp broad emission peak centered at the 3000 nm.

Figure 7 shows dark characteristics of I-V in the anterior and reverse direction of heterozygous cells MnS. The forward current of the heterojunction is very small at a voltage lower than 1.2 V. The current is known as the

Fig. 8: Variation of $\ln(I)$ with bias voltage of MnS heterojunction

Fig. 9: Characteristic under forward reverse bias for MnS

recirculation current at low voltages only. It is created when each excited electron forms the equivalence range of the conductive band. The second high voltage zone represents the area of propagation or bending which depends on serological resistance. In this region; the bias voltage can deliver electrons with enough energy to penetrate the barrier between the two sides of the junction.

Figure 8 shows that the variation of $\ln(I)$ with bias voltage of MnS heterojunction. The ideality factors of heterojunctions are estimated Ideality factor was found to be around 4.8.

Figure 9 shows that the characteristics of the inverse current of the measured instrument in the light current under the tungsten lamp illumination 26.6, 20.4 and 14.2 W/cm². It can be observed that the inverse current value in a standard voltage of hetero-diode meters under luminance is higher than that in the dark and can be seen from Fig. 9 that the current value in a certain voltage of the opposite connectors under the illumination is higher than in the darkness, generation of the current caused by the carrier due to electron-hole production due to light absorption. This behavior produces useful information about electron hole pairs which are effectively generated in the link by the photons that occur.

Figure 10 shows a linear relation between inverse of square of Capacitance ($1/C^2$) reverse bias voltage for MnS, indicating abrupt junction. The built-in potential V_{bi}

Fig. 10: The $1/C^2$ versus reverse voltage of MnS photodiode

Fig. 11: Spectral detectivity as a function of wavelength of MnS photodiode

value were obtained after extrapolating the $(1/C^2)$ point to the voltage axis. The built-in potential V_{bi} for MnS was 1.2 V.

Figure 11 shows that the spectrum detectivity curve in MnS consists of two reaction peaks; the first peak is at 450 nm due to the absorption margin of MnS nanoparticles while the second is located at 800 ± 50 nm as a result of absorption of the silicon edge.

CONCLUSION

The MnS heterojunction was successfully fabricated by using thermal evaporation technique at different temperature. The I-V characteristics of heterojunction MnS are strongly dependent on the structure. The silicon improves the performance MnS show a good transparency in the spectral range 400-900 nm and the electrical characteristics of heterojunction are strongly dependent on the structure. The maximum value of spectral Responsivity $R(\lambda)$ of MnS photodetector is around 0.165 A/W at 450 ± 50 nm. The maximum value of the specific Detectivity $D(\lambda)$ is found to be $2.359 \times 10^{12} \text{ W}^{-1} \text{ cm Hz}^{-1}$ located at 450 ± 50 nm wavelength for MnS photodetector.

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